

JOURNAL OF SOLID STATE CHEMISTRY

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Cover Art. Atomic configurations in $(MC)_l(T_4C_3)_m$ ($M = \text{Zr, Y and Hf}$, $T = \text{Al, Si and Ge}$). $(l, m) = (1, 1)$ in (a), $(2, 1)$ in (b), $(3, 1)$ in (c), $(1, 2)$ in (d) and $(2, 2)$ in (e). Article by K. Sugiura *et al.* on pp. 1619–1623 of this issue.